

The Influence of Electrochemical Treatment on Electrode Reactions for Vanadium Redox Flow Batteries

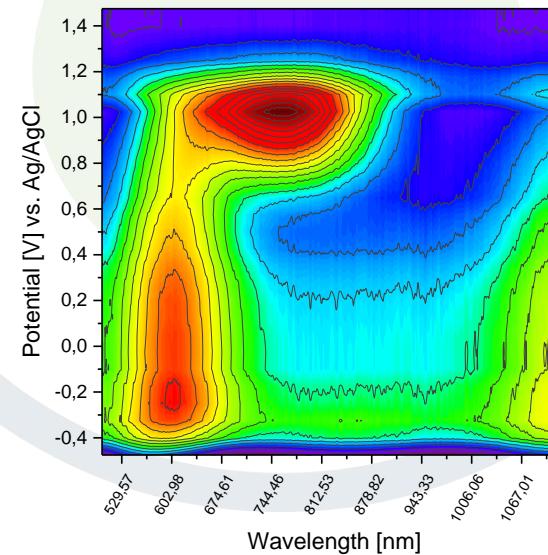
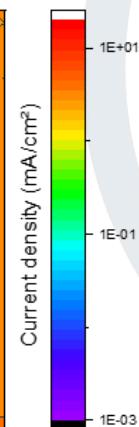
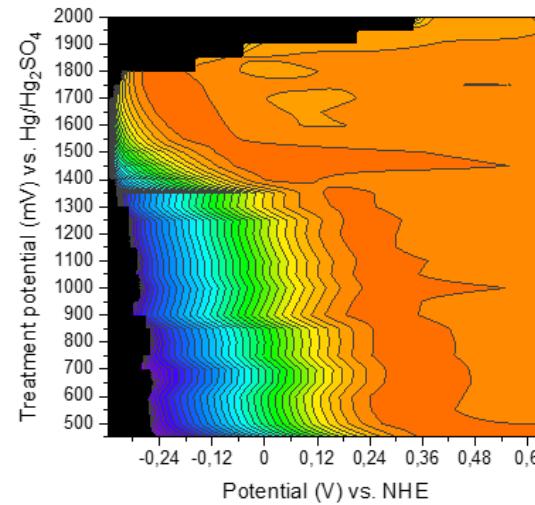
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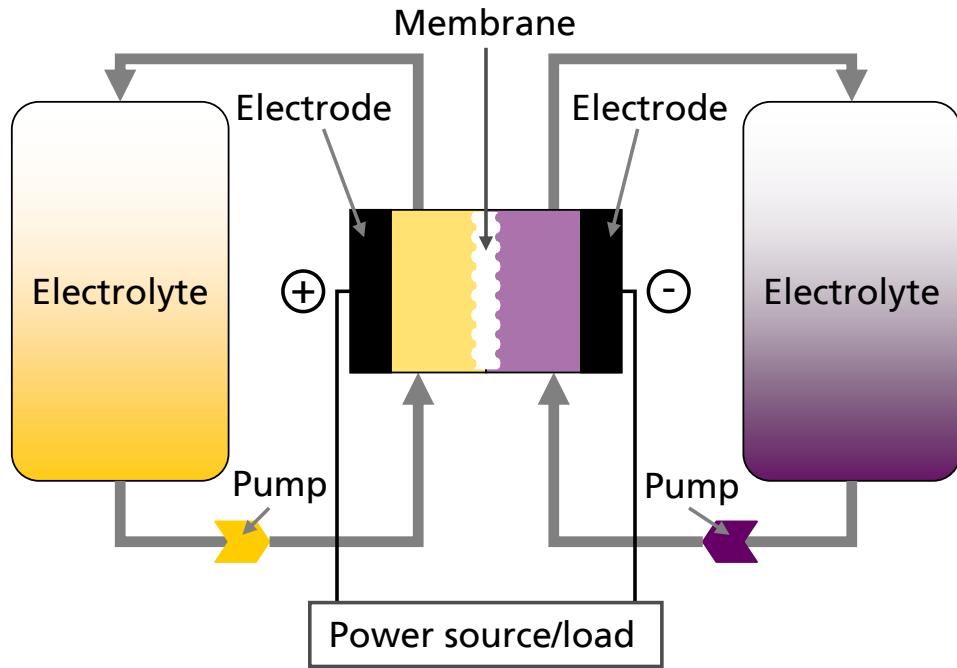
² German-Australian Alliance for Electrochemical Technologies for Storage of Renewable Energy, Mechanical and Manufacturing Engineering, University of New South Wales (UNSW), UNSW Sydney NSW 2052 Australia

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241nd Meeting of The Electrochemical Society, Vancouver, Canada, 2022



Vanadium redox flow battery - working principle



$$\varphi_{cell} = \varphi^+ - \varphi^- + \varphi_M \sim 1.4 \text{ V}$$



W. Kango, „Verfahren zur Speicherung von elektrischer Energie“, German Patent 914264, 1949

W. Kango, H. Pieper, „Zur Frage der Speicherung von elektrischer Energie in Flüssigkeiten“, Electrochimica Acta Vol. 7, 435 – 448, 1962

M. Skyllas-Kazacos, M. Rychcik, R. G. Robins, A. G. Fane, M. A. Green, Journal of The Electrochemical Society 1986, 133, 1057–1058.

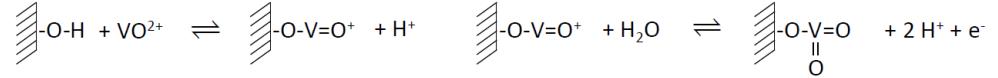
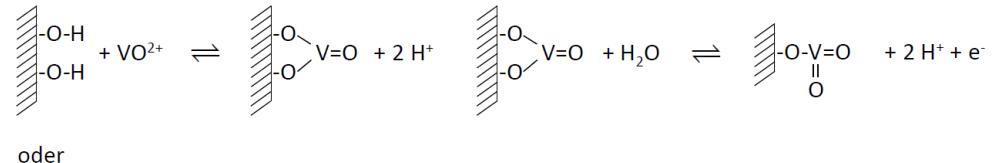
Motivation

- Strong dependence of V-reactions on carbon electrode surface
- Still unclear reason for this behavior
 - Functional groups
 - Edges, surface roughness,...
- It is known that power density of VRFB can be increased dramatically by electrode treatment
- Higher power density decreases the cost of the batteries
- Electrode behavior changes with potential!

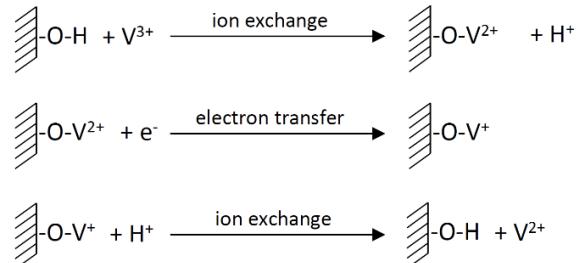


- Study of the most simple systems
- Linear sweeps at glassy carbon electrodes
- Study of the influence of electrochemical treatment on the behavior of vanadium reactions

Oxidation of VO^{2+} at phenolic C-OH groups



Reduction of V^{3+} at phenolic C-OH groups



Experimental

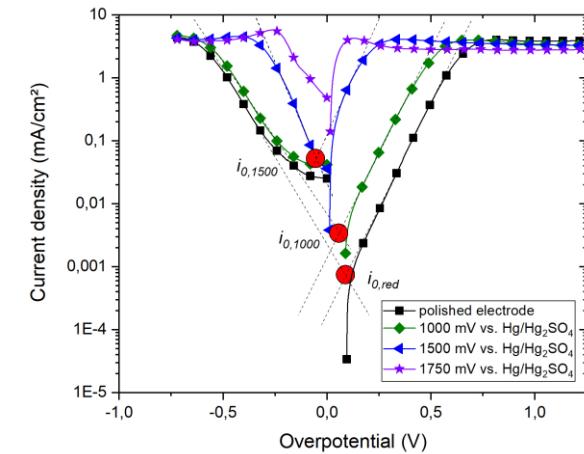
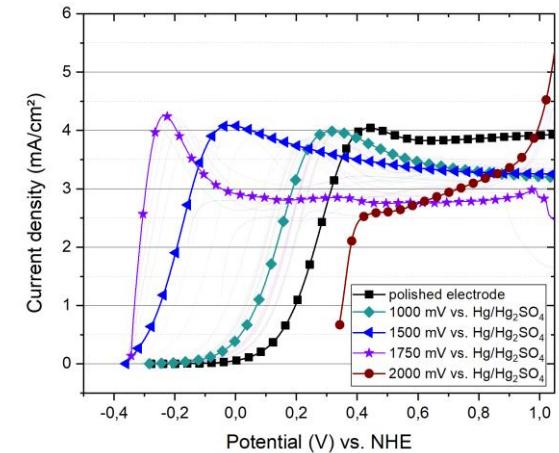
Electrolytes:

- 0.1 M VSO_4 and 0.1 M $\text{V}_2(\text{SO}_4)_3$ in 2 M H_2SO_4 (Made by re-crystallisation!)
- 0.1 M & 1.6 M VOSO_4 in 2 M H_2SO_4
- 0.1 M V_2O_5 in 2 M H_2SO_4

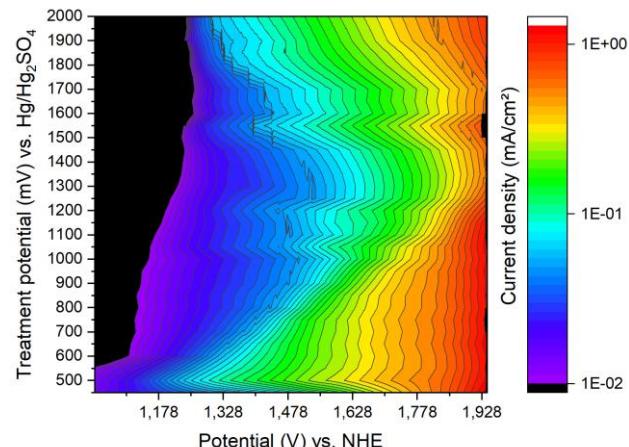
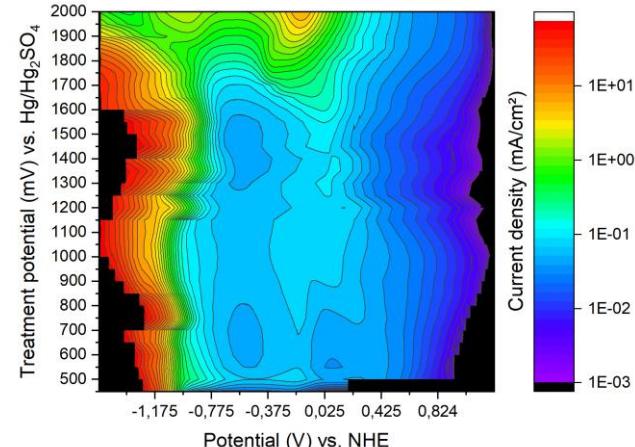
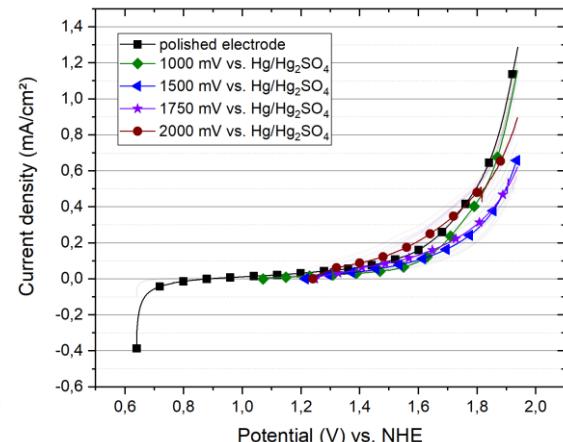
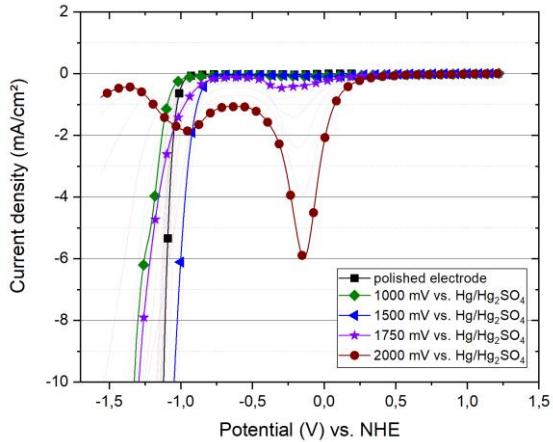
Electrochemical measurement procedure:

1. Polished glassy carbon disc 1 mm diameter (30 x 6 micron, 30 x 1 micron, 30 x 0.25 micron diamond polishing paste, MetaDi II, Buehler, Germany)
➤ Polished electrode (virtual value of 450 mV treatment potential!)
 2. Electrochemical treatment in 2 M H_2SO_4 for 30 s at potentials from +500 mV to +2000 mV vs. $\text{Hg}/\text{Hg}_2\text{SO}_4$, difference 50 mV
 3. Linear sweep voltammetry from OCP in direction of reduction or oxidation with scan rate of 10 mV/s
 4. Calculation of reference current density i_{ref} and 3D heat map plots
-
- **XPS measurements** (Axis Ultra, Kratos Analytical, Manchester, UK)
 - **Laser confocal microscopy** (μ surf custom, Nanofocus AG, Germany)

LSVs and Tafel plots, ox. 0.1 M V^{2+}



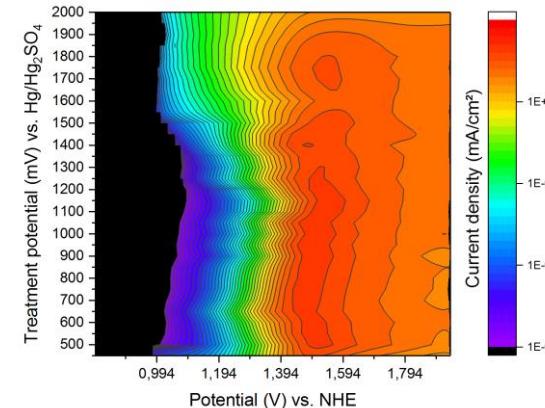
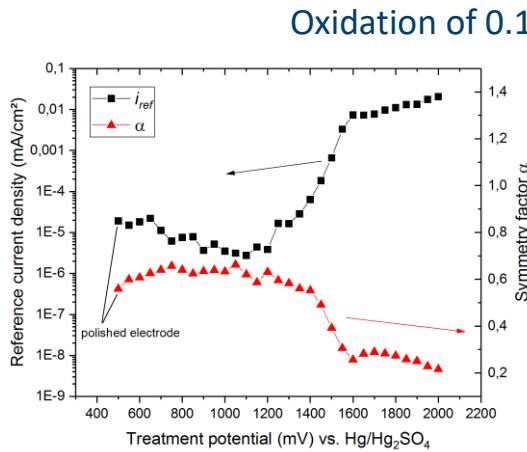
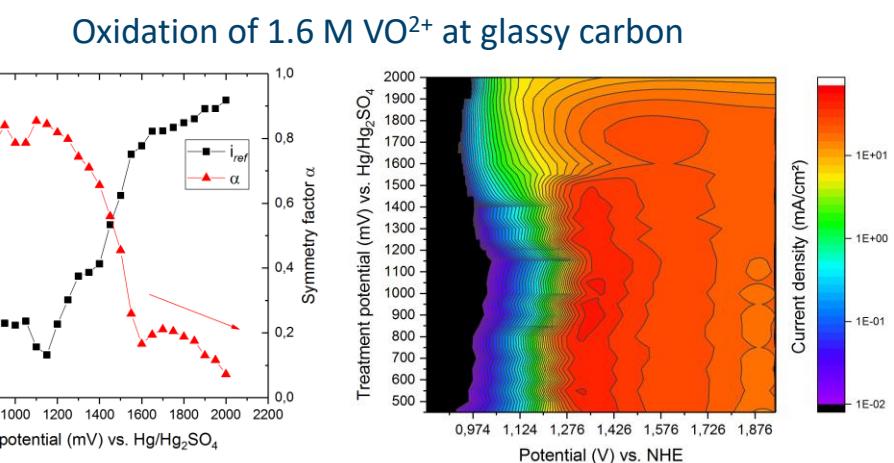
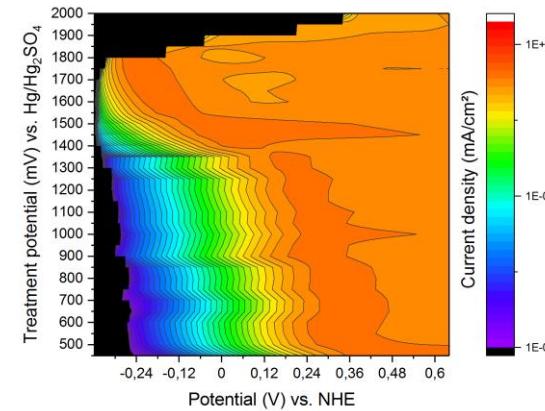
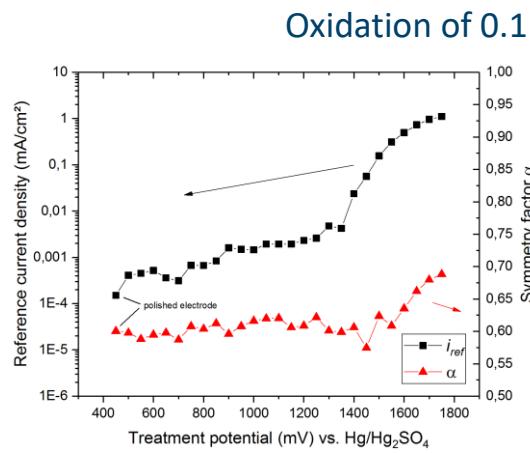
Results & Discussion - Background 2 M H₂SO₄



- Hydrogen and oxygen evolution (or CO_x)
- Strong dependence of the general behavior on treatment potential
- Peaks at around +0.3 V (Q/HQ)
- Additional peaks clearly visible at high treatment potentials

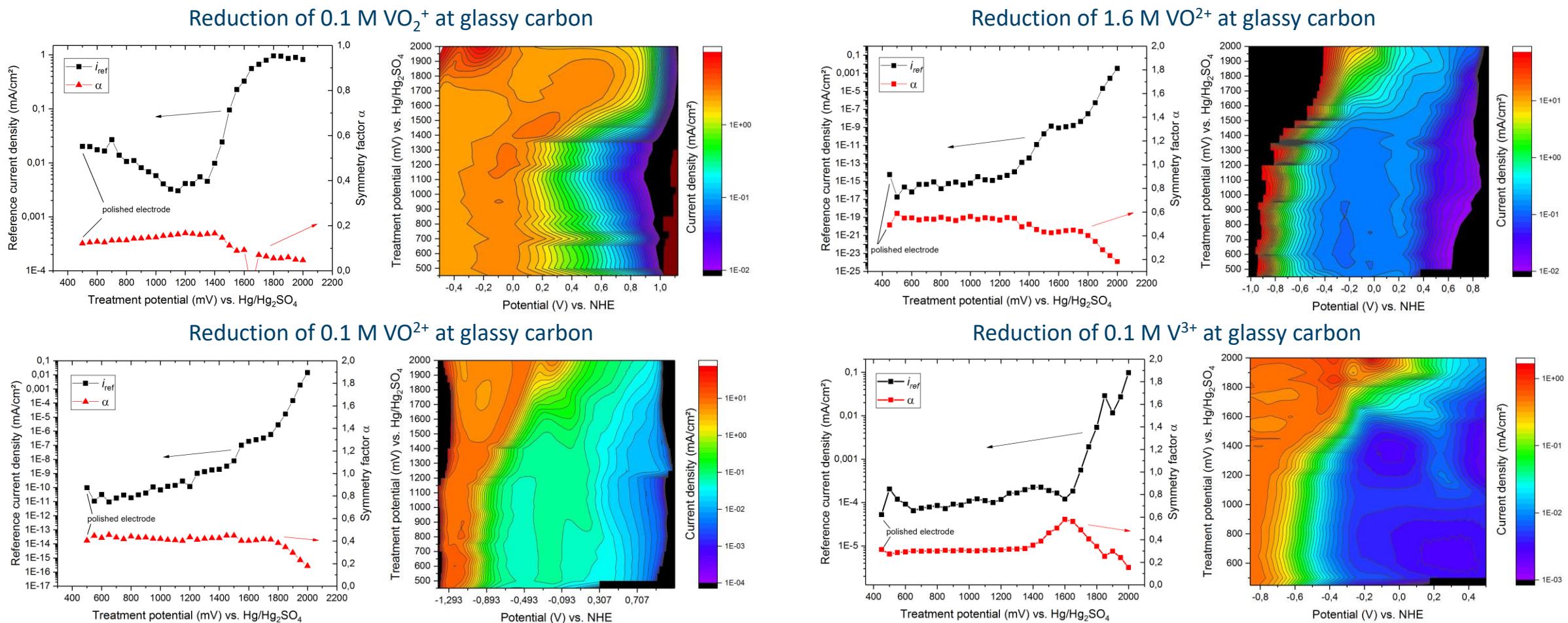
- Several peaks and plateaus in the cathodic area without clear tendency, except appearance of peak at -0.1 V
 - Perhaps O₂ reduction
 - Plateaus with reduction of surface oxides ?
- Clear tendencies in the anodic area!
 - Peak of low oxygen evolution kinetics at ~1.3 V

Results & Discussion - Oxidation processes V(II) -> V(III), V(IV) -> V(V)



- Not shown here: Oxidation of V(III) is a very special process!
- Significant tendencies for all reactions
 - Kinetics of all reactions increases dramatically
 - $V^{2+} \rightarrow V^{3+}$ kinetics continuously increases
 - $V^{IV} \rightarrow V^{V}$ kinetics has a minimum
 - 1.6 M and 0.1 M V(IV) show the same behavior

Results & Discussion - Reduction processes



Results & Discussion - Reduction of V(IV) & Laser confocal microscopy

- Oxo-vanadium - Continuous increase of kinetics with treatment potential
- Non-oxo-vanadium - Minimum of kinetics at ~ 1200 mV vs. NHE
- Exception: Reduction of V(IV):



E fast



C' fast



E slow



E fast



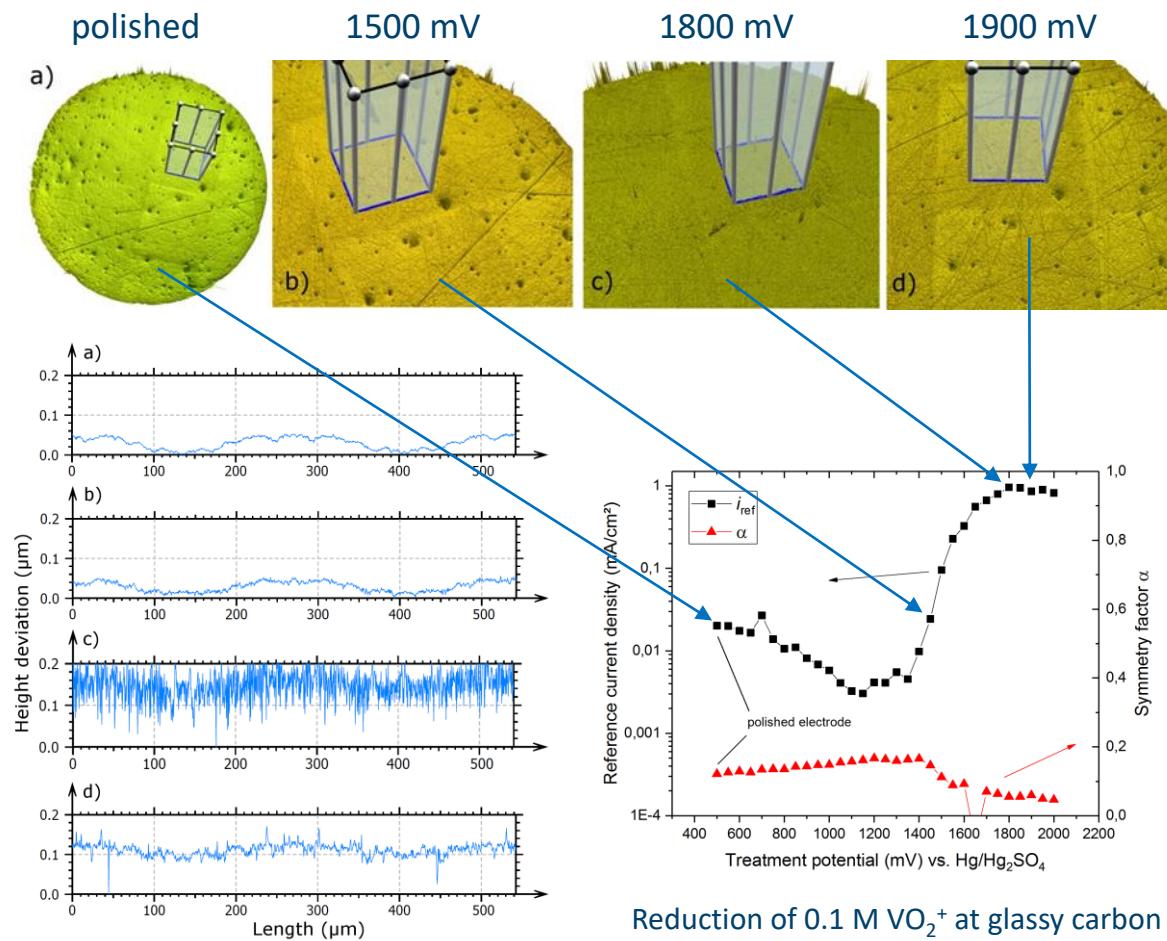
E slow



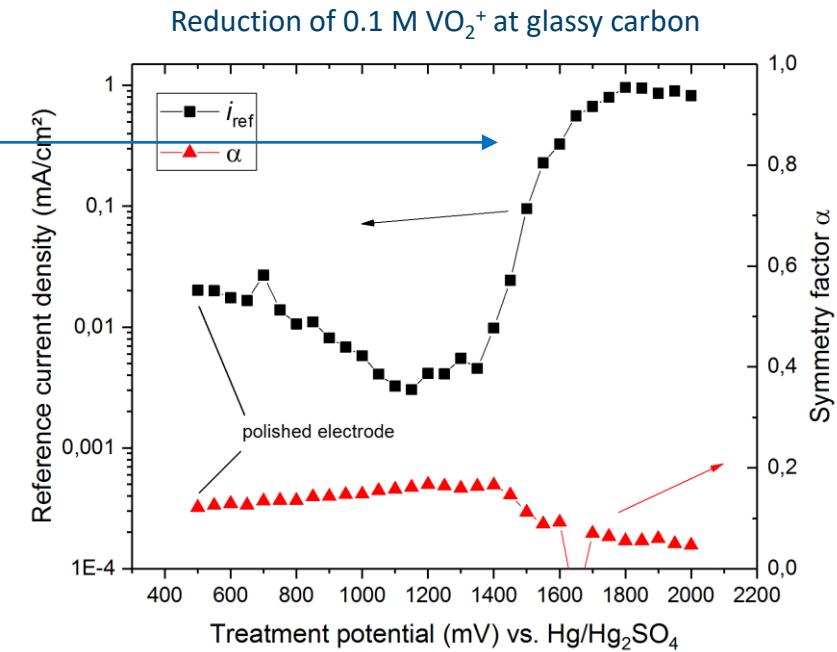
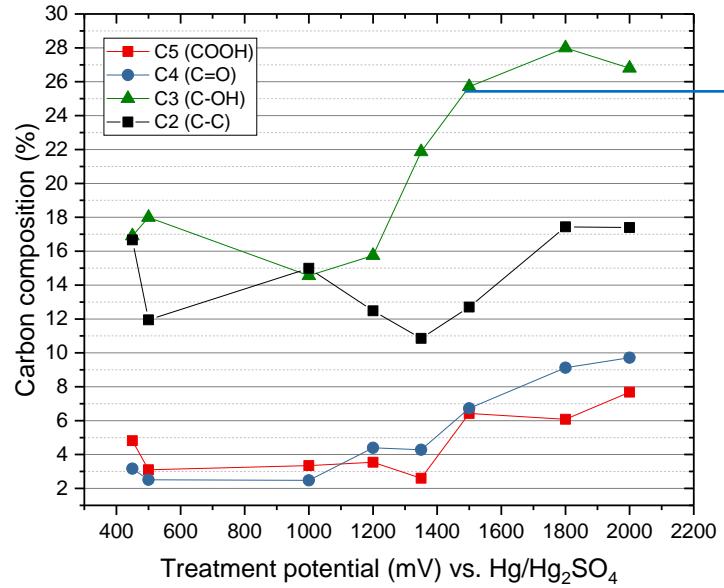
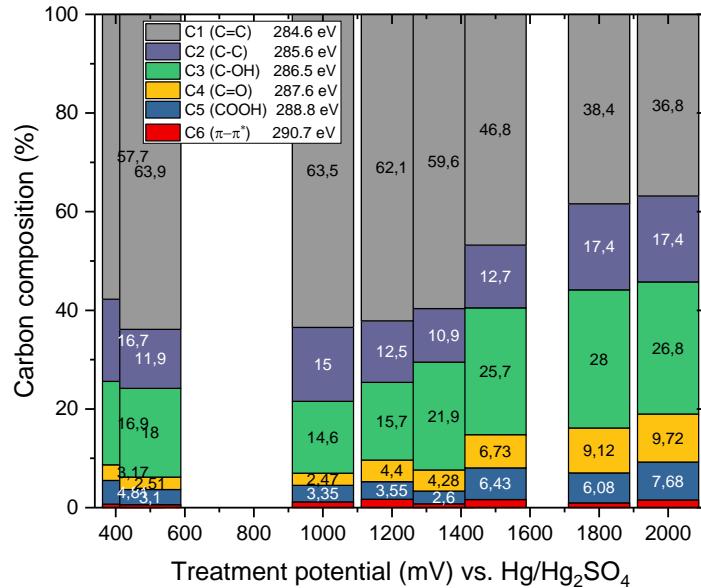
C' fast

- Two path ways possible
- Similar trend to reduction of $V^{3+} \rightarrow C-1$ and $B-2$ must be speed determining steps

Laser confocal microscopy



Results & Discussion - XPS Measurements



-> No correlation with surface roughness but weak correlation with functional groups:

-C-OH for $\text{VO}^{2+}/\text{VO}_2^+$,
-COOH for $\text{V}^{2+}/\text{V}^{3+}$

Conclusions & further work

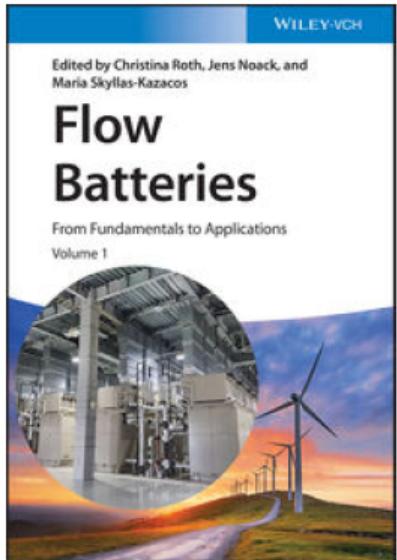
Conclusions

- Studied electrochemical reactions of V(II) -> V(III), V(IV) -> V(V), V(V) -> V(IV), V(IV) -> V(III), V(III) -> V(IV) on GC
- All reactions are strongly surface sensitive
- Electrochemical surface treatment is able to increase kinetics of all reactions dramatically
- No correlation with confocal microscopy electrode surface
- Non-oxo-vanadium reactions V(II) -> V(III), V(III) -> V(II)
 - Continous increase of kinetics with treatment potential
 - Weak correlation with -COOH functional surface groups
- Oxo-vanadium reactions V(IV) -> V(V), V(V) -> V(IV)
 - Increase of kinetics with treatment potential, but minimum at ~1200 mV vs. Hg/Hg₂SO₄
 - Weak correlation with -C-OH functional surface groups

Further work

- More XPS values needed for significant tendencies
- Different techniques could give more additional information
- In-Situ activation of reactions in a battery possible?





Flow Batteries: From Fundamentals to Applications, 2 Volume Set

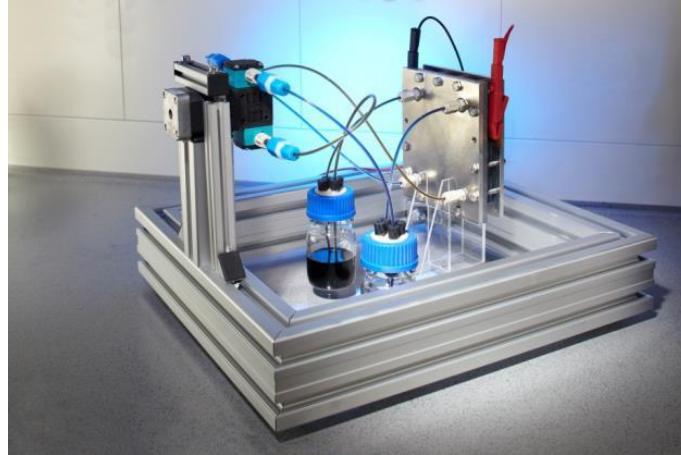
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Thank you for your attention!



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